

Form PTO-1449  <b>INFORMATION DISCLOSURE CITATION IN AN APPLICATION</b> (Use several sheets if necessary)			ATTY DOCKET NO. 32860-000901/US		APPLICATION NO. NEW APPLICATION	
			APPLICANT(S) Dr. Walter GUMBRECHT et al.		CONF. NO. Unknown	
			FILING DATE June 20, 2005		GROUP Unknown	

  

U.S. PATENT DOCUMENTS						
EXAMINER INITIAL	DOCUMENT NUMBER	DATE	NAME	CLASS	SUB CLASS	FILING DATE IF APPROPRIATE
/L.E./	US 2004/063152 A1	04-01-2004	GUMBRECHT et al.			
/L.E./	US 2002/0028441 A1	03-07-2004 <sup>2</sup>	HINTSCHE et al.			

  

FOREIGN PATENT DOCUMENTS							
EXAMINER INITIAL	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUB CLASS	TRANSLATION	
						YES	NO
/L.E./	WO 00/62047	10-19-2000	WIPO			Abstract	
/L.E./	WO 9012314	10-18-1990	WIPO			Abstract	
/L.E./	WO 00/63682	10-26-2000	WIPO			X	
/L.E./	WO 0242759 A1	05-30-2002	WIPO			Abstract	
/L.E./	DE 19610115	09-18-1997	GERMANY			Abstract	
/L.E./	DE 10015816	10-18-2001	GERMANY			Abstract	
/L.E./	WO 98/19153	05-07-1998	WIPO			X	

  

OTHER DOCUMENTS	
(Include Name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.) date, page(s), volume-issue number(s), publisher, city and/or country where published.)	
/L.E./	M. Paeschke et al.: Voltammetric Multichannel Measurements Using Silicon Fabricated Microelectrode Arrays, Electroanalysis 8, No. 10, S. 891-899, 1996
/L.E./	R. Hintsche et al.: Microbiosensors Using electrodes Made in Si-Technology, Frontiers in Biosensorics, Fundamental Aspects, edited by F.W. Scheller et al., Dirk Hauser Verlag, Basel, S. 267-283, 1997
/L.E./	German Translation Aid <span style="float: right;">Date Unknown</span>
/L.E./	German Office Action Dated 03-24-2005
/L.E./	International Search Reports (English and German) dated 05-05-2004

  

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